	L#	Hits	Search Text	DBs
1	L1	42	((microcontact or micro adj contact) near3 print\$4).ti,ab.	US- PGPUB
2	L2	3715	imprint\$4.ti,ab.	USPAT US- PGPUB ;
3	L3	47640	(lithograph\$6 or photolithograph\$6 or mask or photomask or reticle).ti,ab.	USPAT US- PGPUB
4	L4	140	(1 or 2) and 3	USPAT US- PGPUB ; USPAT
5	L 5	41142	(photo adj lithograph\$6 or photolithograph\$6 or mask or photomask or reticle).ti,ab.	US- PGPUB ; USPAT
6	L6	85	(1 or 2) and 5	US- PGPUB ; USPAT
7	L7	9791	(magnetic adj2 head).ti,ab.	US- PGPUB ; USPAT
8	L8	1311	p2.ti,ab.	US- PGPUB ; USPAT
9	L9	43	7 and 8	US- PGPUB ; USPAT
10	L10	1	plating adj compensation	US- PGPUB ; USPAT
11	L11	9	compensation near3 plating	US- PGPUB ; USPAT
12	L12	202	compensation adj area	US- PGPUB ; USPAT

	L#	Hits	Search Text	DBs
13	L13	0	9 and 12	US- PGPUE ; USPAT
14	L14	168042 7	plat\$4 or electroplat\$6 or electro or electrodeposit\$6 or electrolytic\$6 or electrocoat\$6 or electroform\$6	
15.	L15	9	12 same 14	US- PGPUE ; USPAT
16	L16	5118	430/320,322,325,396.ccls.	US- PGPUB ; USPAT
17	L17	19	(1 or 2) and 16	US- PGPUB ; USPAT
18	L18	1455	360/126.ccls.	US- PGPUB ; USPAT
19	L19	0	(1 or 2) and 18	US- PGPUB ; USPAT
20	L20	10	krause-rainer\$.in.	US- PGPUB ; USPAT
21	L21	14	schmidt-markus\$.in.	US- PGPUB ; USPAT
22	L22	21	20 or 21	US- PGPUB ; USPAT
23	L23		(microcontact or micro adj contact) near3 print\$4	EPO; JPO; DERW ENT; BM_T DB

		L#	Hits	Search Text	DBs
	24	L24	9340	imprint\$4	EPO; JPO; DERW ENT; IBM_T DB
	25	L25	242376	photo adj lithograph\$6 or photolithograph\$6 or mask or photomask or reticle	EPO; JPO; DERW ENT; IBM_T DB
4	26	L26	279	(23 or 24) and 25	EPO; JPO; DERW ENT; IBM_T DB
2	27	L27	64494	stamp\$4	EPO; JPO; DERW ENT; IBM_T DB
2	8	L28	22	26 and 27	EPO; JPO; DERW ENT; IBM_T DB
2	9	L29	762925	magnetic	EPO; JPO; DERW ENT; IBM_T DB
3	0	L31	9	26 and 29	EPO; JPO; DERW ENT; IBM_T DB
3	1		2371 5 7 8	plat\$4 or electroplat\$6 or electro or electrodeposit\$6 or electrolytic\$6 or electrocoat\$6 or electroform\$6	EPO; JPO; DERW ENT; IBM_T DB

	L#	Hits	Search Text	DBs
32	L33	101315	compensation	EPO; JPO; DERW ENT; IBM_T DB
33	L34	3401	32 with 33	EPO; JPO; DERW ENT; IBM_T DB
34	L35		• •	EPO; JPO; DERW ENT; IBM_T DB
35	L36	5	32 with 35	EPO; JPO; DERW ENT; IBM_T DB